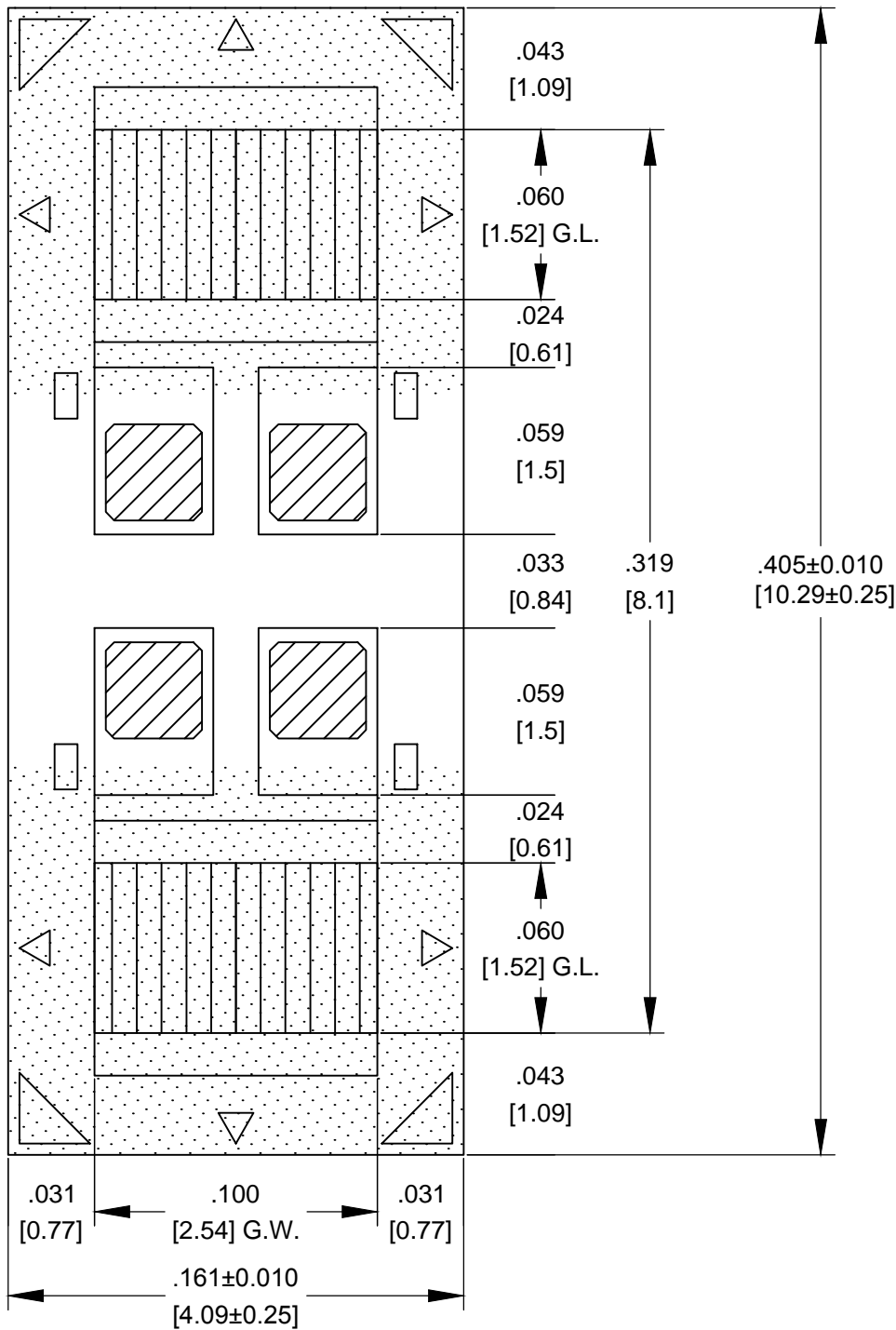


|     |          |     |         |            |
|-----|----------|-----|---------|------------|
| LTR | REVISION | ERN | INITIAL | DATE       |
| ~   |          |     | OS      | 2017-03-07 |



THESE MATRIX RELATED DIMENSIONS ARE ±.0025 [±0.06]

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Micro-Measurements  
Raleigh, North Carolina USA



## S5269 PATTERN LAYOUT

CONSTRUCTION:

N2K

OPTIONS:

E5, DG

RESISTANCE:

350±0.2%

REFERENCE:

DRAWN BY:

OS

PROJ. ENG.

AH

DATE:

2017-03-07

DATE:

2017-03-07

SCALE:

N.T.S.

DWG. #

MS-S5269-10424

ALL DIMENSIONS ARE IN INCHES

[mm].

REVISION:

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